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Surface Science 600 (2006) 793–802

SURFACE SCIENCE

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Autocatalytic partial reduction of FeO(111) and $Fe₃O₄(111)$ films by atomic hydrogen

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> Received 25 August 2005; accepted for publication 22 November 2005 Available online 27 December 2005

Abstract

The interaction of atomic hydrogen with thin epitaxial FeO(111) and Fe₃O₄(111) films was studied by TDS, XPS and LEED. On the thin, one Fe–O bilayer thick FeO film, partial reduction occurs in two steps during exposure. It ends after removal of 1/4 monolayer (ML) of oxygen with a 2 \times 2 pattern appearing in LEED. This FeO_{0.75} film is passive against further reduction. The first reduction step saturates after removal of ~ 0.2 ML and shows autocatalytic kinetics with the oxygen vacancies formed during reduction causing acceleration. The second step is also autocatalytic and is related with reduction to the final composition and an improvement of the 2×2 order. A structure model explaining the two-step reduction is proposed. On the thick $Fe₃O₄$ film, irregular desorption bursts of H₂O and H_2 were observed during exposure. Their occurrence appears to depend on the film quality and thus on surface order. Because of the healing of reduction-induced oxygen vacancies by exchange of oxygen or iron with the bulk, a change of the surface composition was not visible. The existence of partially reduced oxide phases resistant even to atomic hydrogen is relevant to the mechanism of dehydrogenation reactions using iron oxides as catalysts.

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Keywords: Low energy electron diffraction; X-ray photoelectron spectroscopy; Temperature programmed desorption; Catalysis; Surface chemical reaction; Hydrogen atom; Iron oxide

1. Introduction

Iron oxides, widespread in nature, are of interest to many scientific disciplines from geology to biology [\[1\].](#page--1-0) The reduction of iron oxides is inevitable in many processes, such as metallurgy, corrosion, and heterogeneous catalysis. It was long found that the very rapid dissolution of the passive iron oxide films on iron involves a reductive mechanism [\[2\]](#page--1-0). The surface reduction, together with coke formation, is responsible for the deactivation of the iron oxide-based catalyst for the dehydrogenation of ethylbenzene to styrene [\[3,4\].](#page--1-0) Because of their relevance for corrosion processes, the reduction of iron oxides in solution has been extensively studied and a clear understanding of the mechanism and kinetics is acquired [\[5\]](#page--1-0). However, fundamental understanding of iron oxide reduction by gas phase hydrogen is poor.

Most fundamental understanding of the gas–solid interactions comes from surface science studies of relevant model systems under ultra-high-vacuum (UHV) conditions. Very little is known about the interaction of hydrogen with well-characterized single-crystal iron oxides. The nearly stoichiometric, well ordered α -Fe₂O₃(0001) surface is inert towards molecular hydrogen at room temperature and interaction occurs only at defects [\[6\].](#page--1-0) Thus it is difficult to approach the reduction of iron oxides by employing molecular hydrogen. The reason is, of course, the high dissociation energy of $H₂$ (432 kJ/mol). Atomically adsorbed hydrogen, OH groups or protons are formed in catalytic

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^{0039-6028/\$ -} see front matter \oslash 2005 Elsevier B.V. All rights reserved. doi:10.1016/j.susc.2005.11.026

dehydrogenation reactions or during electrochemical reduction. Therefore it makes sense to study the interaction of surfaces with atomic hydrogen Hat which should be able to interact with almost any surface. Since this interaction may be violent, defect formation and other structural changes may be expected. It has been shown that Ni(111) exposed to H_{at} under UHV condition can form bulk hydrogen species, which show a unique catalytic activity towards hydrogenation of hydrocarbons [\[7\].](#page--1-0) H atoms were also reported to readily adsorb on the $ZnO(0001)$ surface [\[8,9\]](#page--1-0).

Here we present a surface science study on the interaction of atomic hydrogen with iron oxides. We observe an autocatalytically accelerated partial reduction of the oxides. This represents a new type of autocatalytic surface reactions, different to autocatalytic reactions of or between adsorbates studied so far like decomposition of formic acid $[10,11]$ acetic acid $[12-15]$ or the reactions of CO with NO [\[16–21\]](#page--1-0), NO with H₂ or NH₂ [\[17,22–24\]](#page--1-0) and H₂ with O₂ [\[25\]](#page--1-0).

After the experimental section, results on the interaction of H_{at} with a thin epitaxial FeO(111) film are presented and discussed. It will be shown that this model system is easy to analyse and allows to understand the finally presented phenomena on a thicker epitaxial $Fe₃O₄(111)$ film more clearly.

2. Experimental

The experiments were performed in an ultra-high-vacuum (UHV) chamber with a base pressure in the 10⁻¹¹ mbar range. It was equipped with a display LEED optics (Omicron), a hemispherical electron energy analyser (Phoibos 150, Specs), a dual anode X-ray source (VSW, used line $AIK\alpha$) for XPS and a quadrupole mass spectrometer (QMS, Balzers Prisma) for TPD. The QMS was equipped with an entrance cone (3 mm diameter) so that only gas from the sample center could enter the QMS directly. Signals are uncalibrated and shown as measured.

A $Pt(111)$ sample (9 mm diameter, 1.5 mm thick) with type K thermocouple spot welded to its edge was mounted on a sapphire support which could be introduced into the chamber via a transfer system [\[26\].](#page--1-0) The epitaxial oxide films were prepared as described earlier [\[26\]](#page--1-0) by evaporating iron from an Fe wire wrapped around a heated W filament, followed by a proper oxidation cycle in 10^{-6} mbar O₂. For the $FeO(111)$ film, about 1 ML Fe was evaporated and oxidized at 1000 K which resulted in a film one Fe–O bilayer thick [\[27\].](#page--1-0) Its structure was checked by LEED and corresponded to the structure typical for the full bilayer (structure S2 according to [\[27\]\)](#page--1-0). The $Fe₃O₄(111)$ film was prepared by sequences of Fe depositions, 5–10 ML each, followed each time by short oxidation at about 900 K. Finally, the film was oxidized at slowly increasing T with $T_{\text{max}} = 1000$ K until LEED showed a clear pattern. No signal from the Pt substrate could be detected in XPS. The film was thus at least about 10 nm thick.

A high efficiency source for atomic hydrogen (H_{at}) was constructed following the ideas of Bischler and Bertel [\[28\]](#page--1-0). The hydrogen gas passes through a W capillary the tip of which is heated by electron bombardment to about 2000 K resulting in a high degree of dissociation. The capillary is surrounded by a copper heat shield. At the sample position 4 cm in front of the capillary, the diameter of the Hat jet is large enough to yield a fairly homogeneous exposure. Given exposure values (in Langmuir units, $1 \text{ L} = 1.33 \times 10^{-6} \text{ mbar s}$ refer to the H₂ background pressure and are relative values concerning H_{at} . The actual exposures to H_{at} are unknown but from the observed reaction rates we can conclude that they have a similar magnitude. Thermal desorption spectra were taken at a heating rate of 4.3 K s^{-1} .

In the case of FeO, exposures were performed at 300 K. In order to separate the unavoidable desorption of H_2 from the heater (filament and its surrounding) from sample desorption, the sample was cooled to 230 K before starting TPD. The desorption peak from the heater extended up to about 330 K but since its shape was fairly independent of the preceding exposure to H_{at} , it could be subtracted from the TPD traces. H_2O did not desorb from the heater. Since both H_2 and H_2O are main constituents of the residual gas, a linear background was subtracted. Especially the H_2O background depended on the chamber history and varied within a factor of 5. This is the reason for different noise levels.

In the case of Fe₃O₄, exposures were performed at 355 K and TPD started after cooling to 300 K.

3. Results and discussion

3.1. H_2 on FeO(111) and Fe₃O₄(111)

The interaction of molecular hydrogen with the oxide films was tested by exposing them at room temperature to 1000 L $H₂$. The changes of the LEED patterns and of the XP-spectra of O 1s and Fe 2p are negligible and we ascribe them rather to the residual water formed by reaction with the chamber walls during exposure than to the direct interaction with $H₂$. One reproducible effect was an apparent shift of all XP-spectra by about 0.1–0.2 eV towards higher binding energy directly after pumping off the admitted gas. This shift disappears within about 30 min without any other spectral changes. Therefore we assign it to reversible H_2 -induced work function changes in the analyser. Similar shifts were also observed after exposure to Hat which generates a high H_2 background pressure.

3.2. H_{at} on $FeO(111)$ – results

[Fig. 1](#page--1-0) shows background-corrected TPD results for desorption of H_2 and H_2O from the FeO(111) film exposed at room temperature to increasing amounts of H_{at} between 0.2 and 10 L. After each exposure and TPD run, the film was reoxidized and it was checked by LEED that the clean Download English Version:

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